INTERNATIONAL STANDARD

ISO/IEC 11695-1

First edition
2008-11-01

Identification cards — Optical memory cards — Holographic recording method —

Part 1: Physical characteristics

Cartes d'identification — Cartes à mémoire optique — Méthode d'enregistrement holographique —

Partie 1: Caractéristiques physiques

Reference number
ISO/IEC 11695-1:2008(E)

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Published in Switzerland

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Foreword

ISO (the International Organization for Standardization) and IEC (the International Electrotechnical Commission) form the specialized system for worldwide standardization. National bodies that are members of ISO or IEC participate in the development of International Standards through technical committees established by the respective organization to deal with particular fields of technical activity. ISO and IEC technical committees collaborate in fields of mutual interest. Other international organizations, governmental and non-governmental, in liaison with ISO and IEC, also take part in the work. In the field of information technology, ISO and IEC have established a joint technical committee, ISO/IEC JTC 1.

International Standards are drafted in accordance with the rules given in the ISO/IEC Directives, Part 2.

The main task of the joint technical committee is to prepare International Standards. Draft International Standards adopted by the joint technical committee are circulated to national bodies for voting. Publication as an International Standard requires approval by at least 75 % of the national bodies casting a vote.

ISO/IEC 11695-1 was prepared by Joint Technical Committee ISO/IEC JTC 1, *Information technology*, Subcommittee SC 17, *Cards and personal identifcation*.

ISO/IEC 11695 consists of the following parts, under the general title *Identification cards — Optical memory cards — Holographic recording method*:

— *Part 1: Physical characteristics*

— *Part 2: Dimensions and location of accessible optical area*

— *Part 3: Optical properties and characteristics*

Introduction

ISO/IEC 11695 is one of a series of International Standards defining the parameters for optical memory cards and the use of such cards for the storage and interchange of digital data.

These International Standards recognize the existence of different methods for recording and reading information on optical memory cards, the characteristics of which are specific to the recording method employed. In general, these different recording methods will not be compatible with each other. Therefore, these International Standards are structured to accommodate the inclusion of existing and future recording methods in a consistent manner.

ISO/IEC 11695 is specific to optical memory cards using the holographic recording method. Characteristics which apply to other specific recording methods are found in separate International Standards.

This part of ISO/IEC 11695 defines the physical characteristics and the extent of compliance with, addition to, and/or deviation from the relevant base document, ISO/IEC 11693.

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Identification cards — Optical memory cards — Holographic recording method —

Part 1: Physical characteristics

1 Scope

This part of ISO/IEC 11695 defines the physical characteristics of optical memory cards using the holographic recording method.

2 Normative references

The following referenced documents are indispensable for the application of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

ISO/IEC 7810, *Identification cards — Physical characteristics*

ISO/IEC 7816-1, *Identification cards — Integrated circuit(s) cards with contacts — Part 1: Physical characteristics*

ISO/IEC 10373-1, *Identification cards — Test methods — Part 1: General characteristics*

ISO/IEC 11695-2, *Identification cards — Optical memory cards — Holographic recording method — Part 2: Dimensions and location of accessible optical area*

ISO/IEC 11695-3 *Identification cards — Optical memory cards — Holographic recording method — Part 3: Optical properties and characteristics*

3 Terms and definitions

For the purposes of this document, the terms and definitions given in ISO/IEC 11695-2, ISO/IEC 11695-3 and the following apply.

3.1
holographic recording method
writing and/or pre-formatting of digital data on the holographic memory card in the form of holograms

3.2
hologram
microscopic structure which can be written by optical energy into an accessible optical area causing diffraction of a read-out beam of certain wavelength by illumination

NOTE 1 A hologram is the representation of a two-dimensional code of digital data on the holographic memory card.

NOTE 2 See Annex A.

3.3
amplitude hologram
hologram which modulates the amplitude of a read-out beam in the read-out process

3.4
phase hologram
hologram which modulates the phase of a read-out beam in the read-out process

3.5
thick hologram
hologram in which the thickness is *n* times the wavelength of the writing/reading beam, where *n* >10

3.6
thin hologram
hologram characterized by the thickness of the recording medium containing the hologram, whereby the hologram has the same order as the wavelength of the writing/reading beam

3.7
holographic memory card
card containing an accessible optical area to which holograms can be written using external optical energy

3.8
accessible optical area
partition of the holographic memory card which is available to be accessed by the read and/or write beam of the holographic read-out and/or recording system used

3.9
storage layer
specific layer of the holographic memory card, located between the protective layer and the reflective layer, which contains specific materials to permit writing and/or reading back holographic recorded data by optical means

3.10
protective layer
transparent layer of material within the holographic memory card which is placed on top of the storage layer and able to provide protection against scratches, humidity and damage caused by environmental influence

3.11
reflective layer
layer of material within the holographic memory card placed between substrate layer and storage layer to reflect the writing and reading beam so that the holographic memory card can be read out in reflection mode

3.12
substrate layer
layer of material of an holographic memory card providing a flat and smooth surface for both the reflective and storage layers attaching the storage medium to the card body, when the substrate layer is not the card body

3.13
polarization
property of electromagnetic waves, such as light, that describes the direction of the transverse electric field

NOTE The polarization of a transverse wave describes the direction of oscillation in the plane perpendicular to the direction of travel.

3.14
birefringence
decomposition of a ray of light into two rays (the ordinary ray and the extraordinary ray) when it passes through certain types of material, depending on the polarization of the light

NOTE This effect occurs when the structure of the material is anisotropic.

4 Holographic memory cards – physical characteristics

4.1 Dimensions

4.1.1 Card height and width

ISO/IEC 7810 applies.

4.1.2 Card thickness

ISO/IEC 7810 applies.

4.1.3 Card corners

ISO/IEC 7810 applies.

4.1.4 Card edges

ISO/IEC 7810 applies.

4.2 Construction

4.2.1 Card construction

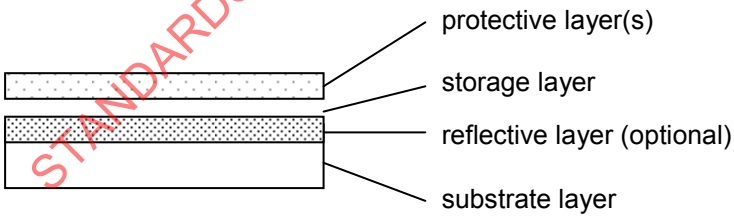
ISO/IEC 7810 applies.

4.2.2 Cross-section at accessible optical area

See Figure 1.

The holographic memory card contains an accessible optical area which is laminated, bonded, or inserted into the card body.

The accessible optical area is composed of different layers: a substrate layer, a reflective layer, a storage layer and one or more protective layers to protect the sub-layers from damage, e.g. by surface damage, humidity and other environmental influence.



NOTE Drawing not to scale.

Figure 1 — Cross-section of a holographic memory card at the accessible optical area

4.3 Physical characteristics

4.3.1 Protective layer(s)

There are one or multiple protective layers to protect the sub-layers (storage layer, reflective layer) from surface damage, humidity and other environmental influence.

The protective layer has to be transparent for the writing and reading beam.

When using reading or writing light with linear or circular polarization, the protective layer has to be free of birefringence.

The protective layer ensures that the holographic memory card can survive the action of a destructive influence to the extent that it continues to show optical characteristics which conform to the base standard. Destructive influences are specified in ISO/IEC 10373-1.

4.3.2 Storage layer

The storage layer is a photosensitive material applied to the reflective or substrate layers. Examples of materials, which can be used are:

— high-resolution photographic silver-halide film (e.g. Kodak 649F, Agfa 8E75HD),

— silver-halide sensitized gelatin (e.g. BB-640 from Holographic Recording Technologies),

— dichromated gelatin (DCG) (e.g. Geola PFG-04),

— photoresists (e.g. Shipley AZ-1350),

— photopolymers (e.g. Dupont OmniDex),

— functionalized comb-shaped liquid crystalline polymers (see bibliography item [12]).

The thickness of the storage layer may vary depending on the specific optical characteristics of the material chosen. To be in compliance, materials used shall conform to the optical requirements as specified in ISO/IEC 11695-3.

The material composing the storage layer determines the parameters for recording and reading of holograms (wavelength of writing/reading beam, writing/reading power) as well as the type of holograms, which can be recorded (thin hologram/thick hologram, amplitude/phase). The material as well as the parameters for recording and/or reading holograms shall be specified by the card manufacturer.

4.3.3 Reflective layer

The reflective layer is necessary when the hologram is read out in reflection mode for thin holograms. The reflective layer is metallic: metals which can be used include aluminium, silver, gold, titanium and chromium. The thickness of the reflective layer may vary depending on the specific optical characteristics of the selected material. To be in compliance, materials and thickness of reflective layer shall conform to the reflectivity requirements as specified in ISO/IEC 11695-3. Typical thickness values of metallic layers vary between 50 nm and 200 nm.

4.3.4 Substrate layer

The substrate layer can be the card body itself; it can consist of the same materials as the card body or it can be made of other material which provides a flat and smooth surface on one side and the ability to attach the optical (holographic) storage medium on the other.

The surface roughness (Ra) of the substrate layer shall be less than 100 nm.

The thickness of the substrate layer may vary depending on the materials used and the manufacturing process employed.

4.3.5 Additions

The addition of integrated circuit chips with or without contacts, tipping, embossing, magnetic stripe materials, and/or signature panel materials shall not alter the characteristics of the holographic memory card to the extent that, during normal use of the card, the accessible optical area is likely to become incapable of meeting the characteristics specified for it in this part of ISO/IEC 11695.

4.3.6 Bending stiffness

ISO/IEC 7810 applies.

4.3.7 Card warpage

ISO/IEC 7810 applies.

4.3.8 X-rays

ISO/IEC 7816-1 applies.

4.3.9 Toxicity

ISO/IEC 7810 applies.

4.3.10 Ultraviolet light

ISO/IEC 7816-1 applies.

4.3.11 Light transmittance

ISO/IEC 7810 applies.

4.3.12 Bending properties

ISO/IEC 7816-1 applies.

4.3.13 Resistance to chemicals

ISO/IEC 7810 applies.

4.3.14 Atmospheric requirements

The card shall still function in accordance with this part of ISO/IEC 11695 when exposed to

— gaseous concentrations of less than 0,1 parts per million of SO_2, H_2S, or NO_x ,

NOTE NO_x means NO, NO_2 or a mixture of NO and NO_2.

— salt (NaCl) concentrations of less than 2,7 µg/m^3.

4.3.15 Durability

ISO/IEC 7810 applies.

4.3.16 Dimensional stability and warpage with temperature and humidity

ISO/IEC 7810 applies.

4.3.17 Default test environment and conditioning

ISO/IEC 10373-1 applies, as well as the following conditions.

— Atmospheric pressure: 75 kPa to 105 kPa.

— Condensation: none permitted.

Annex A
(informative)

Holographic data storage

A.1 Holographic data storage

Holography is a general recording method by coherent light beams, which can be used for any information recording – from digital to pictorial and volume imaging. Holography is a two step process. In the first step (recording) a hologram is produced from an object. In the second step (read-out) an image of the object is reconstructed from the hologram by illumination.

A.1.1 Creation of holograms

A hologram is produced from an object. One method to produce a hologram is by the interference of two light beams, the object beam and the reference beam: a scattered beam from the object interferes with the reference beam the resulting interference pattern is called hologram of the object. The hologram can then be recorded on a photosensitive medium.

The object can be a real three-dimensional object (volume object). It can also be a two-dimensional image of a digital code (e.g. matrix or bar code), which can be applied to the object beam by an amplitude modulator.

This method of producing holograms is depicted in Figure A.1

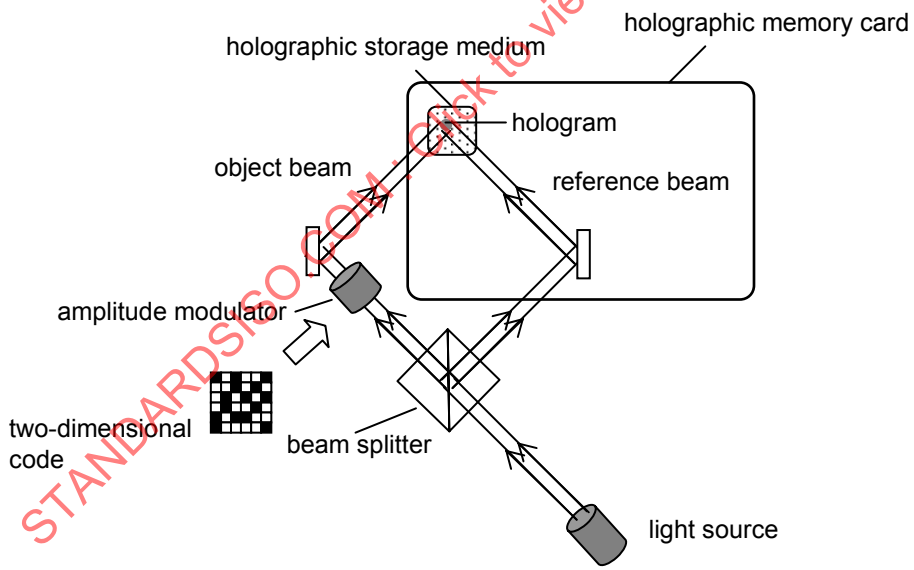


Figure A.1 — Schematic overview of a setup for holographic data storage by overlapping two coherent light beams

A.1.2 Read-out of holograms

For the read-out, the hologram is illuminated with a beam, having the same or similar properties to the reference beam used for the production of the hologram under the same angle of incidence used in the recording step. Holographic imaging is a wave front reconstruction process: by illuminating the hologram with the reference beam the object wave is reconstructed. The scattered light from the hologram produces an image of the object, which can be captured by a camera.

The read-out process is depicted in Figure A.2

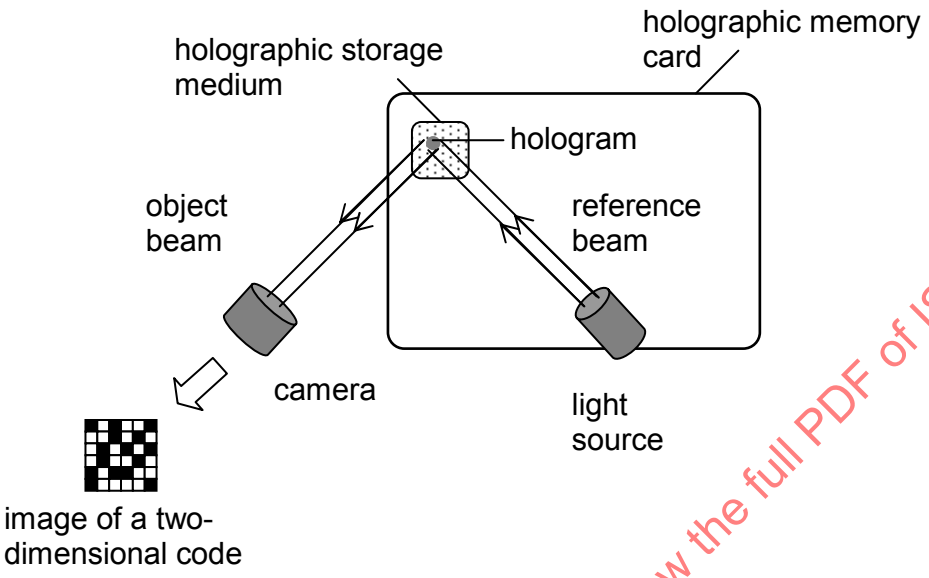


Figure A.2 — Setup for reading out a hologram

A.2 Types of hologram

A.2.1 Reflection and transmission holograms

Reflection and transmission holograms differ in the geometry of the read-out process. Reflection holograms are read out in reflection mode, meaning the light source for the read-out beam and the camera are located on the same side of the hologram (holographic memory card). Transmission holograms are read out in transmission mode, meaning the light source for the read-out beam and the camera are located on opposite sides of the hologram (holographic memory card).

The storage medium for transmission holograms shall be transmissive for the read-out beam whereas the storage medium for reflection holograms shall incorporate a reflective layer for the read-out beam.

A.2.2 On-axis and off-axis holograms

On- and off-axis holograms differ in viewing angle. On-axis holograms are illuminated by the readout beam perpendicularly incident to the hologram (incident angle 90°). Off-axis holograms are illuminated by the read-out beam under an incident angle differing from 90°. Both methods are depicted in Figure A.3.